IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Hamada et al.

Filed: Concurrently Herewith

Title: COMPOSITION FOR FORMING POROUS FILM, POROUS FILM AND

METOHD FOR FORMING THE SAME, INTERLAYER INSULATOR FILM,

AND SEMICONDUCTOR DEVICE

Docket No.: 035576/275943

Customer No.: 00826

March 23, 2004

Mail Stop Patent Application Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

PRELIMINARY AMENDMENT 37 CFR § 1.115

Sir:

Please enter this Preliminary Amendment before calculating the claim fee and amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims beginning on page 2 of this paper.

Remarks begin on page 10 of this paper.